IN THE CLAIMS

Please amend the claims as follows:

1. (Currently Amended): A process of reforming a quartz glass crucible, wherein the quartz glass crucible is reformed by an arc discharge generated by electrodes positioned around a rotational axis and configured to heat an inside surface of the crucible while the crucible is rotated, the process comprising:

arranging the electrodes in an electrode structure in which neighboring electrodes are positioned at regular intervals from each other in a ring-like configuration;

determining a phase of an electric current based on a number and an arrangement of the electrodes;

forming a stable ring-like arc between the neighboring electrodes, without generating a continuous arc between electrodes facing each other across a central portion of the ring-like configuration, by controlling applying electric current of the determined phase to the electrodes;

heating the inside surface of the crucible while the crucible is rotated; and removing one of a foreign substance located on the inside surface and a bubble located under the inside surface.

2. (Original): The process of claim 1, wherein the arranging step comprises: arranging the electrodes in the electrode structure such that the neighboring electrodes are positioned at regular intervals in the ring-like configuration so as to have an absolute value θ of a phase difference of alternating electric current in the range of $90^{\circ} \leq \theta \leq 180^{\circ}$.

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- 3. (Original): The process of claim 1, wherein a radius r of the ring-like configuration around the rotational axis is at least ¼ of a radius R of an open portion of the crucible, for at least a fixed time during arc heating.
- 4. (Original): The process of claim 1, wherein a diameter of the crucible is 28 to 40 inches.
- 5. (Original): The process of claim 1, wherein the quartz glass crucible is used for the pulling up of single crystal silicon.
- 6. (Original): The process of claim 2, wherein a diameter of the crucible is 28 to 40 inches.
- 7. (Original): The process of claim 2, wherein the quartz glass crucible is used for the pulling up of single crystal silicon.
- 8. (Original): The process of claim 2, wherein a radius r of the ring-like configuration around the rotational axis is at least ¼ of a radius R of an open portion of the crucible, for at least a fixed time during arc heating.
- 9. (Original): The process of claim 8, wherein a diameter of the crucible is 28 to 40 inches.
- 10. (Original): The process of claim 8, wherein the quartz glass crucible is used for the pulling up of single crystal silicon.

- 11. (Original): The process of claim 3, wherein a diameter of the crucible is 28 to 40 inches.
- 12. (Original): The process of claim 3, wherein the quartz glass crucible is used for the pulling up of single crystal silicon.
- 13. (Currently Amended): A process of reforming a quartz glass crucible, comprising:

one of mechanically removing a foreign substance on an inside surface of the crucible and removing a bubble just under the inside surface of the crucible by grinding;

arranging electrodes in an electrode structure such that neighboring electrodes are positioned at regular intervals from each other in a ring-like configuration;

determining a phase of an electric current based on a number and an arrangement of the electrodes;

forming a ring-like arc between neighboring electrodes, without generating a continuous arc between electrodes facing each other across a central portion of the ring-like configuration, by controlling applying electric current of the determined phase to the electrodes; and

fusing the inside surface of the crucible to be smoothed.

14. (Original): The process of claim 13, wherein a diameter of the crucible is 28 to 40 inches.

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- 15. (Previously Presented): The process of claim 13, wherein the quartz glass crucible is used for the pulling up of single crystal silicon.
- 16. (Previously Presented) The process of Claim 1, wherein the arranging step comprises arranging nine electrodes at regular intervals in the ring-like configuration, and the forming step comprises applying 3-phase alternating current to the electrodes.
- 17. (Previously Presented) The process of Claim 1, wherein the arranging step comprises arranging eight electrodes at regular intervals in the ring-like configuration, and the forming step comprises applying 4-phase alternating current to the electrodes.